



IFW

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Group Art Unit: 2813
Examiner: Jack S. J. Chen

In Re PATENT APPLICATION of:

Applicant(s): Toshikazu MIZUKOSHI)

Serial No.: 10/635,506)

Filed: August 7, 2003)

For: METHOD OF FABRICATING A)
SEMICONDUCTOR DEVICE TRENCH)
HAVING AN OXIDE FILM ON A)
CORNERED PORTION THEREOF)

Atty. Dkt.: OKI 361)

AMENDMENT

June 27, 2005

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In response to the Examiner's Action mailed on April 20, 2005, please
amend the above-identified application as follows:

PLEASE ENCLOSED: \$
Please charge any further
fee to our Deposit Account
No. 18-0002